This listing of claims will replace all prior versions, and listings of claims in the application:

Listing of Claims:

1914. (Amended) A method of fabricating an integrated circuit, the method comprising:

providing a plurality of inverters as part of said integrated circuit; providing a plurality of MACROs as part of said integrated circuit; providing a first layer of metallization;

providing a second layer of metallization;

utilizing no local interconnect in said second layer of metallization to configure said plurality of inverters;

utilizing said second layer of metallization to connect at least two of said MACROs.

- 2015. (Amended) The method as described in claim 19-14 and further comprising: utilizing in at least one of said MACROs no local interconnect within said second layer of metallization.
- 2116. (Amended) The method as described in claim 19-14 and further comprising: utilizing in a plurality of said MACROs no local interconnect within said second layer of metallization.
- 2217. (Amended) The method as described in claim 19-14 and further comprising: utilizing in all of said MACROs no local interconnect within said second layer of metallization.
- 2318. (Amended) The method as described in claim 19-14 and further comprising; embedded embedding at least one of said MACROs within a standard cell array of said integrated circuit.

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24<u>19</u>. (Amended) The method as described in claim <u>23-14</u> wherein said standard cell array comprises a row pitch, said method further comprising:

utilizing a MACRO having a row pitch equivalent to said standard cell array.

3020. (Amended) An integrated circuit, comprising:

a logic inverter comprising:

an n-channel field effect transistor;

a p-channel field effect transistor;

a gate, formed in a layer of polysilicon; and

a drain of the p-channel field effect transistor and a drain of the n-channel field effect transistor formed in said same layer of polysilicon.

- 3421. (Amended) The integrated circuit as described in claim 3020, wherein the polysilicon comprising said gate is coplanar with the polysilicon comprising said drain of the p-channel field effect transistor and said drain of the n-channel field effect transistor.
- 3222. (Amended) The integrated circuit as described in claim 3020, further comprising:

a first layer of metallization; and

a second layer of metallization, wherein the second layer of metallization comprises substantially no local interconnect.

- 3323. (Amended) The integrated circuit as described in claim 3222, wherein said second layer of metallization comprises no local interconnect.
- 3424. (Amended) The integrated circuit as described in claim 3020, further comprising:

a plurality of MACROs;

a fist layer of metallization; and

a second layer of metallization interconnecting said plurality of MACROs.

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- 3525. (Amended) The integrated circuit as described in claim 3024, further comprising:
- a trace, formed in said layer of polysilicon, wherein said trace connects said drain of said p-channel field effect transistor and said drain of said n-channel field effect transistor.
- 3626. (Amended) The integrated circuit as described in claim 3524, further comprising, no local interconnect within said second layer of metallization in at least one of said MACROs.
- 3727. (Amended) The integrated circuit as described in claim 3524, further comprising, no local interconnect within said second layer of metallization in a plurality of said MACROs.
- 3828. (Amended) The integrated circuit as described in claim 3524, further comprising, no local interconnect within said second layer of metallization in all of said plurality of MACROs.
- 3929. (Amended) The integrated circuit as described in claim 3524, wherein at least one of said MACROs is comprised by a standard cell array of the integrated circuit.
- 4030. (Amended) The integrated circuit as described in claim 3929, wherein said standard cell array comprises a row pitch and at least one MACRO has a row pitch equivalent to the row pitch of said standard cell array.